

**COPOLYMERS CONTAINING POLYAMIDE BLOCKS AND POLYETHER
BLOCKS BASED ON ETHOXYLATED AMINES**

ABSTRACT

The present invention relates to copolymers containing polyamide blocks and polyether blocks based on ethoxylated primary amines, these copolymers having a melting point of between 80°C and 135°C and an MFI (melt flow index) of between 5 and 80 g/10 min (2.16 kg – 150°C).

The invention also relates to adhesives of the HMA (or hot melt adhesive) type consisting of the above copolymers containing polyamide blocks and polyether blocks.